Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	304	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) near6 (metal or copper or cu) near10 (roughness or (amount or concentration) near2 (leveler or brightener))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/07 11:53
S2	1	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) near15 (metal or copper or cu) near15 ((roughness) near4 (leveler or brightener))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/07 11:54
S3	4	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) same ((roughness) near4 (leveler or brightener))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/07 11:55
54	7	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) same ((roughness) near10 (leveler or brightener))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/07 11:56
S 5	396	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) same ((amount or concentration) near10 (leveler or brightener))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2005/02/07 11:57
S6	310	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) same ((amount or concentration) near4 (leveler or brightener))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/07 13:51
S7	51	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plate) same ((adjust or adjusting or adjustment or optimization or optimizing or optimized or changing or selecting or selection or selected or configuring or altering or alteration or altered) near3 (roughness))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/07 13:53
S8	373	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) near15 (rough or roughness or roughened or smoothness or roughen) same (cmp or planarization or planarized or polishing or polished)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 13:45
S9	315	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (leveler or leveling or leveller) near3 (amount or concentration or wt)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 13:46
S10	124	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (leveler or leveling or levelling or leveller) near3 (amount or concentration or wt) and (cmp or planarization or planarizing or polishing or planarized)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 15:02
S11	907	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (roughness or roughened or smoothness or height near2 difference or rough or roughening) near5 (rms or nm or nanometer or ang or angstrom)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON .	2005/02/11 15:08
S12	43	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (copper or cu or metal) near6 (roughness or roughened or smoothness or rough or roughening) near3 (rms or nm or nanometer or ang or angstrom)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 15:14

S13	60	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plate) near10 (copper or cu or metal) and (roughness or roughened or	US-PGPUB; USPAT; EPO; JPO;	OR	ON	2005/02/11 15:55
		smoothness or rough or roughening or height near difference) near (rms or nm or nanometer or ang or angstrom)	DERWENT; IBM_TDB			
S14	14	(metal or copper or cu or silver or ag or nickel or ni or platinum or pt or gold or au) near4 (roughness) same (cmp or ecmp or polishing or planarizing or planarization) and (end or stop or endpoint or finish or finished or complete or completion or done or completed) near2 (detect or detecting or detection or monitor or monitoring or monitored or sensor or sensing or sensed or measure or measured or measuring)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 15:31
S15	28	(metal or copper or cu or silver or ag or nickel or ni or platinum or pt or gold or au) near4 (roughness) and (cmp or ecmp or polishing or planarizing or planarization) and (end or stop or endpoint or finish or finished or complete or completion or done or completed) near2 (detect or detecting or detection or monitor or monitoring or monitored or sensor or sensing or sensed or measure or measured or measuring)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 15:48
S16	27	(metal or copper or cu or silver or ag or nickel or ni or platinum or pt or gold or au) near15 ((roughness or texture) near3 (selection or selected or optimal or optimized or optimization or optimum or selecting or preferred or prefered or ideal or chosen or choosing or chose)) and (cmp or planarization or planarizing or polishing)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 15:51
S17	421	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plating or electro-plated or electro-plate) and (leveler or leveller or levelling or leveling or brightener or additive) near3 (roughness or texture or rough or roughened or texturing or grain or granularity)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 16:10
S18	297	(electrolytic or electrolyte or electroplating or electroplated or electroplate or electro-plate) and (leveler or leveller or levelling or leveling or brightener or additive) near2 (roughness or texture or rough or roughened or texturing or grain or granularity)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/11 16:15
S19	12	(US-20030080000-\$ or US-20030221966-\$ or US-20040012090-\$ or US-20040069650-\$ or US-20040094511-\$ or US-20040258860-\$ or US-20020166773-\$ or US-20020084193-\$ or US-20040076832-\$ or US-20030162399-\$).did. or (US-6444110-\$ or US-6403481-\$).did.	US-PGPUB; USPAT	OR	ON	2005/02/11 16:41